Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	658	(LOCOS or (local adj oxidation adj of adj silicon)) same (remov$3 or etch$3) same vapor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 12:37
L2	51	1 same recess$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 12:35
L3	0	(LOCOS or (local adj oxidation adj of adj silicon)) near3 (remov$3 or etch$3) near vapor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 12:38
L4	0	(LOCOS or (local adj oxidation adj of adj silicon)) near5 (remov$3 or etch$3) near vapor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 13:18
L5	1134	(LOCOS or (local adj oxidation adj of adj silicon)) near5 (remov$3 or etch$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 13:50
L6	553	5 and (trench$2 or groov$2)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 13:23
L7	2	(LOCOS or (local adj oxidation adj of adj silicon)) near5 (remov$3 or etch$3) same (vapor near2 etch$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 13:52
L8	0	(LOCOS or (local adj oxidation adj of adj silicon)) near5 (vapor near2 etch$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 13:53

L9	385	(vapor near2 etch$3) near3 ("HF" or hydrofluoric)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 14:10
L10	165	9 and (silicon adj dioxide)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 13:56
L11	84	(vapor near2 etch$3) near3 ("HF" or hydrofluoric) and (NH3 or ammonia)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 14:14
L12	34	11 and ((thermal near oxid$4) or (silicon adj dixoide) or sio2)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 14:13
L13	7	(vapor near2 etch$3) near3 ("HF" or hydrofluoric) same (NH3 or ammonia)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/01 14:14
S1	0	("10713971").PN.	USPAT	OR	OFF	2005/02/01 12:28
S2	1	("6677646").PN.	USPAT	OR	OFF	2005/01/05 19:32
S3	10	(("6429055") or ("6403433") or ("6225229") or ("6225173") or ("6187620") or ("6184097") or ("6010921") or ("5472897") or ("5468665") or ("5300447")).PN.	USPAT	OR	OFF	2005/01/05 19:34
S4	2	("0139273").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/05 19:35
S5	0	("Wo139273").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/05 19:50

S6	16887	((438/149) or (438/151) or (438/154) or (438/161) or (438/169) or (438/174) or (438/180) or (438/181) or (438/184) or (438/185) or (438/197) or (438/199) or (438/211) or (438/213) or (438/214) or (438/216) or (438/217) or (438/218) or (438/221) or (438/229) or (438/230) or (438/231) or (438/232) or (438/279) or (438/289) or (438/294) or (438/296) or (438/299) or (438/300) or (438/301) or (438/302) or (438/311) or (257/288) or (257/347) or (257/330) or (257/333) or (257/332) or (257/240) or (257/241) or (257/243) or (257/344)).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/05 20:15
S7	3043	S6 and (soi or (silicon adj on adj insulator))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/05 20:17
S8	221	S7 and ((recess$3 or trench$3 or groov$3) near5 (channel or (channel near2 region)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/05 20:19
S9	645	S7 and ((recess$3 or trench$3 or groov$3 or thin$4) near5 (channel or (channel near2 region)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/05 20:19
S10	301	S9 and (spacer$1)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/05 20:22